



Jeffrey L. Moyer

Director

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Jeffrey Moyer's varied litigation practice has led him to try cases in all of Delaware's state and federal courts. Currently his practice focuses primarily on complex commercial and intellectual property litigation.

Praised by *Chambers* as a "talented lawyer with great judgment and client service" (*Chambers USA*, 2018), Jeff has represented some of the world's leading technology companies in intellectual property and licensing disputes in the Delaware District Court and the Delaware Court of Chancery. He also has represented clients in some of the largest civil cases brought in the Superior Court of Delaware. Jeff regularly speaks on litigation practice and ethics, and he contributes to several of the firm's publications concerning litigation practice in Delaware.

Experience

- Represented global semiconductor manufacturer in action alleging infringement of a U.S. patent directed to a coding method for increasing speed and compression ratio for digital image storage
- Represented U.S. based airline accused of infringing two U.S. patents directed to a method and system of facilitating wireless e-commerce transactions
- Represented Delaware limited liability company in complex commercial dispute concerning potentially unlimited environmental liabilities arising out of mining and related businesses which had been transferred numerous times over the course of several decades
- Represented one of the world's largest defense contractors in commercial dispute arising out of asset purchase agreement transferring contractor's business unit
- Represented leading semiconductor chip manufacturer in dispute concerning alleged violations of confidentiality provisions and covenant not to sue in patent portfolio licensing agreement
- Represented international law firm in dispute concerning drafting and enforcement of earn out provisions in asset purchase agreement

- Representing multinational semiconductor manufacturer in toxic tort case relating to fabrication of integrated circuits

Publications

- "U.S. Supreme Court Adopts New Indefiniteness Standard," *Delaware Business Court Insider*, June 25, 2014

Awards

- *Chambers USA*, since 2011
- *IAM Patent 1000 – The World's Leading Patent Professionals*, 2018, 2017, 2016, 2015
- *Benchmark Litigation*, 2018, 2017, 2016, 2015
- *The Best Lawyers in America*, since 2012
- *Best Lawyers' Wilmington, DE Patent Law Lawyer of the Year*, 2018
- *Best Lawyers' Wilmington, DE Copyright Lawyer of the Year*, 2016
- *Super Lawyers*, since 2013
- *Delaware Today Top Lawyer, Top Vote Getter, Litigation*, 2013

Education

- J.D., Temple University School of Law, 1994
- B.S., University of Delaware, 1991

Admitted to Practice

- Delaware
- United States Court of Appeals, Third Circuit
- United States Supreme Court

Practices

- Intellectual Property
- Litigation
- Chancery / Corporate Litigation